

Impact of electron density profile on core impurity behaviour in NBI-heated LHD plasmas

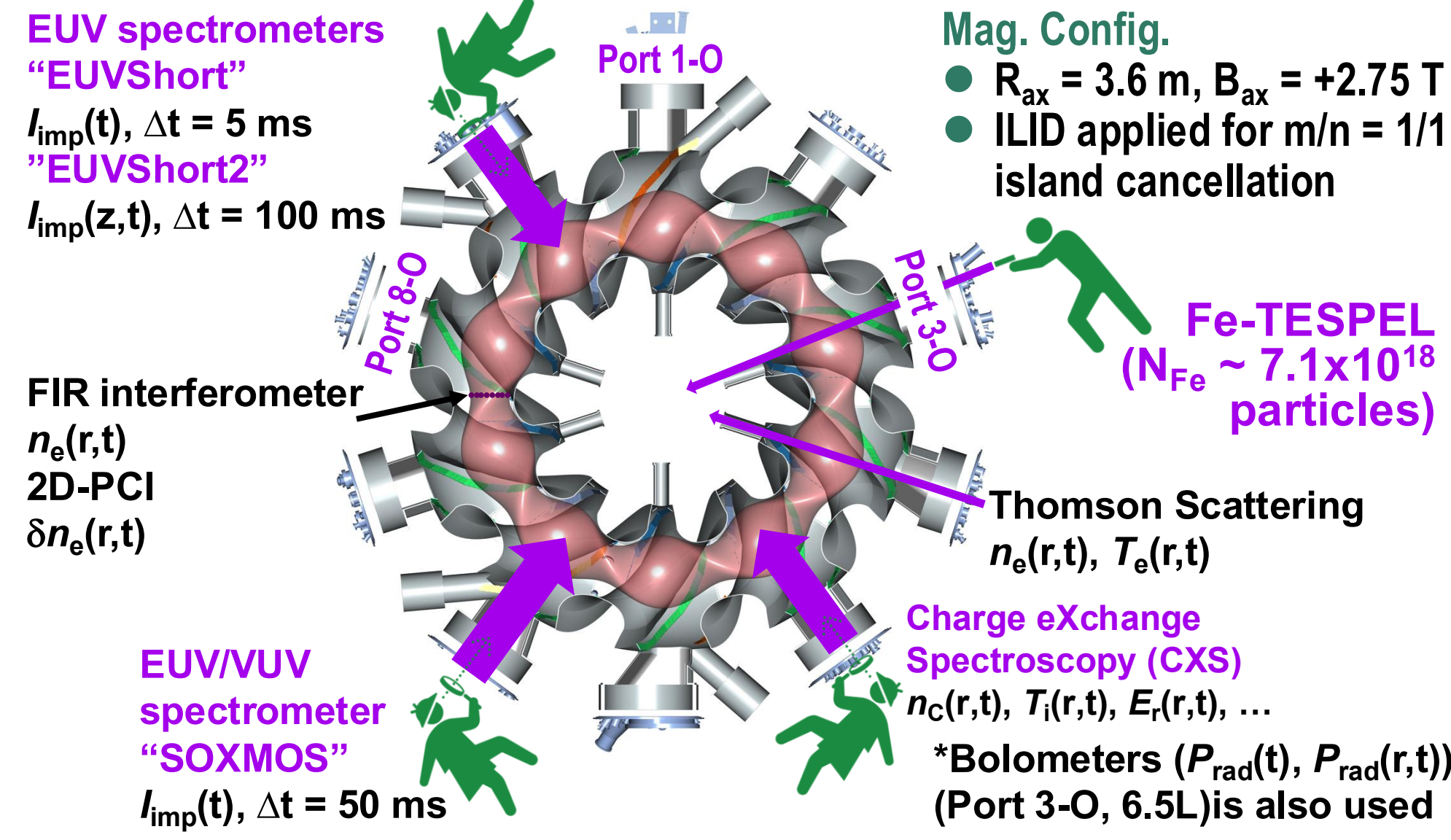
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HIGHLIGHT

- Impact of the electron density profile shape on Fe impurity transport was investigated in NBI-heated LHD plasmas
- A significant reduction in the core T_e was observed only when Fe impurities penetrated deeply into plasmas with a peaked n_e profiles
- However, when comparing cases with shallow Fe deposition, the Fe line emission intensity decayed more rapidly in plasmas with a peaked n_e profile than in plasmas with a flat n_e profile, contrary to expectations
- When impurities were injected into plasmas with a flat n_e profile, low-frequency fluctuations were suppressed regardless of the impurity deposition location

EXPERIMENT SETUP

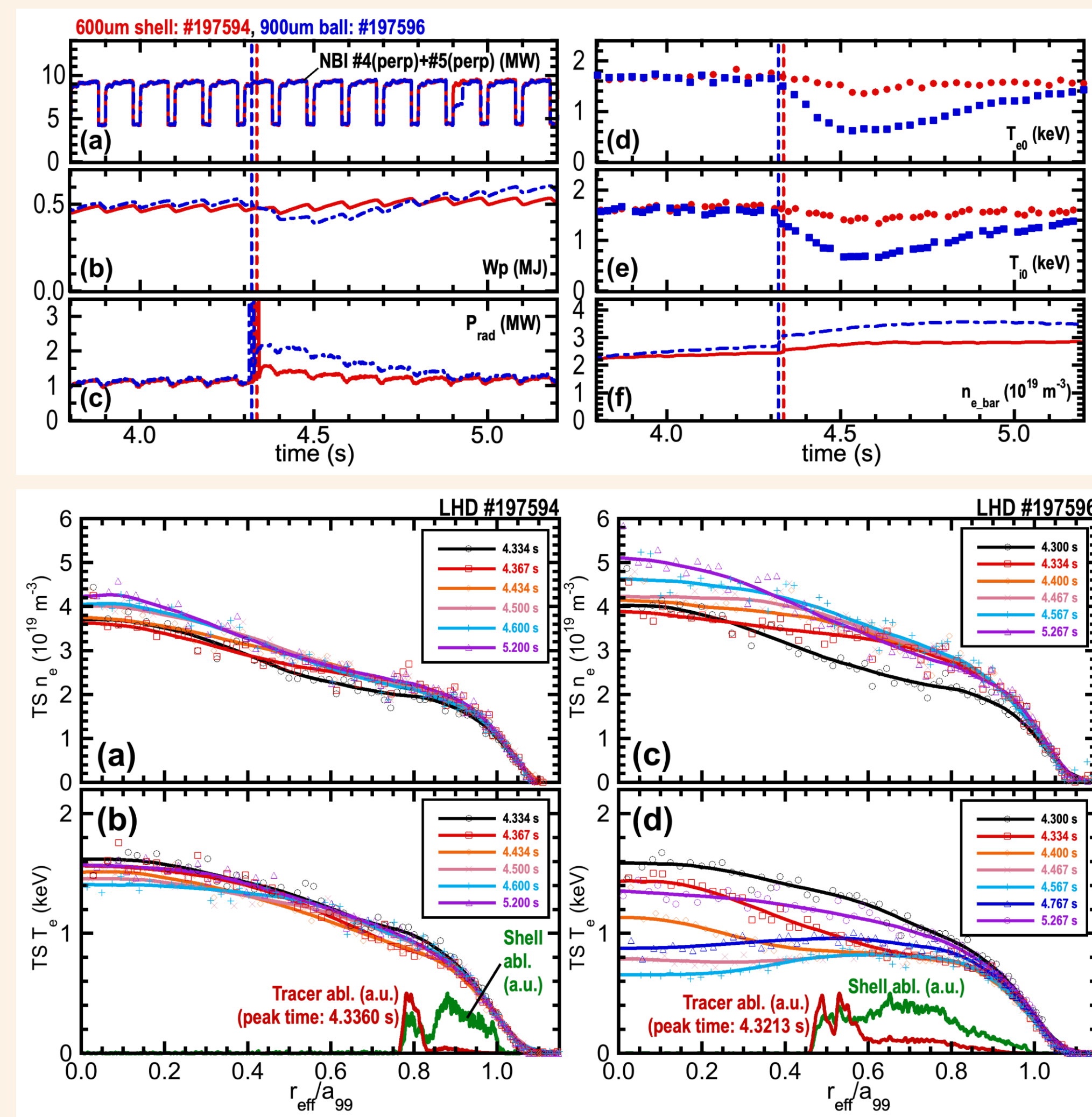


CONCLUDING REMARKS

- Impact of the n_e profile shape on Fe impurity transport was investigated in NBI-heated LHD plasmas using Fe-TESPEL injection
- A significant degradation of the core T_e was observed only when Fe impurities were deposited deeply into plasmas with a peaked n_e profile, indicating enhanced impurity accumulation in the core region
- In contrast, for shallower impurity deposition, Fe line emissions decayed more rapidly in the peaked-density plasma than in the flat-density plasma, suggesting that impurity transport cannot be explained solely by the density profile shape
- Distinct responses of low-frequency n_e fluctuations were observed between the two density-profile configurations, implying a possible coupling between impurity transport and turbulence
- These results indicate that both the impurity deposition location and the background density profile play important roles in determining impurity confinement in LHD plasmas

EXPERIMENTAL RESULTS

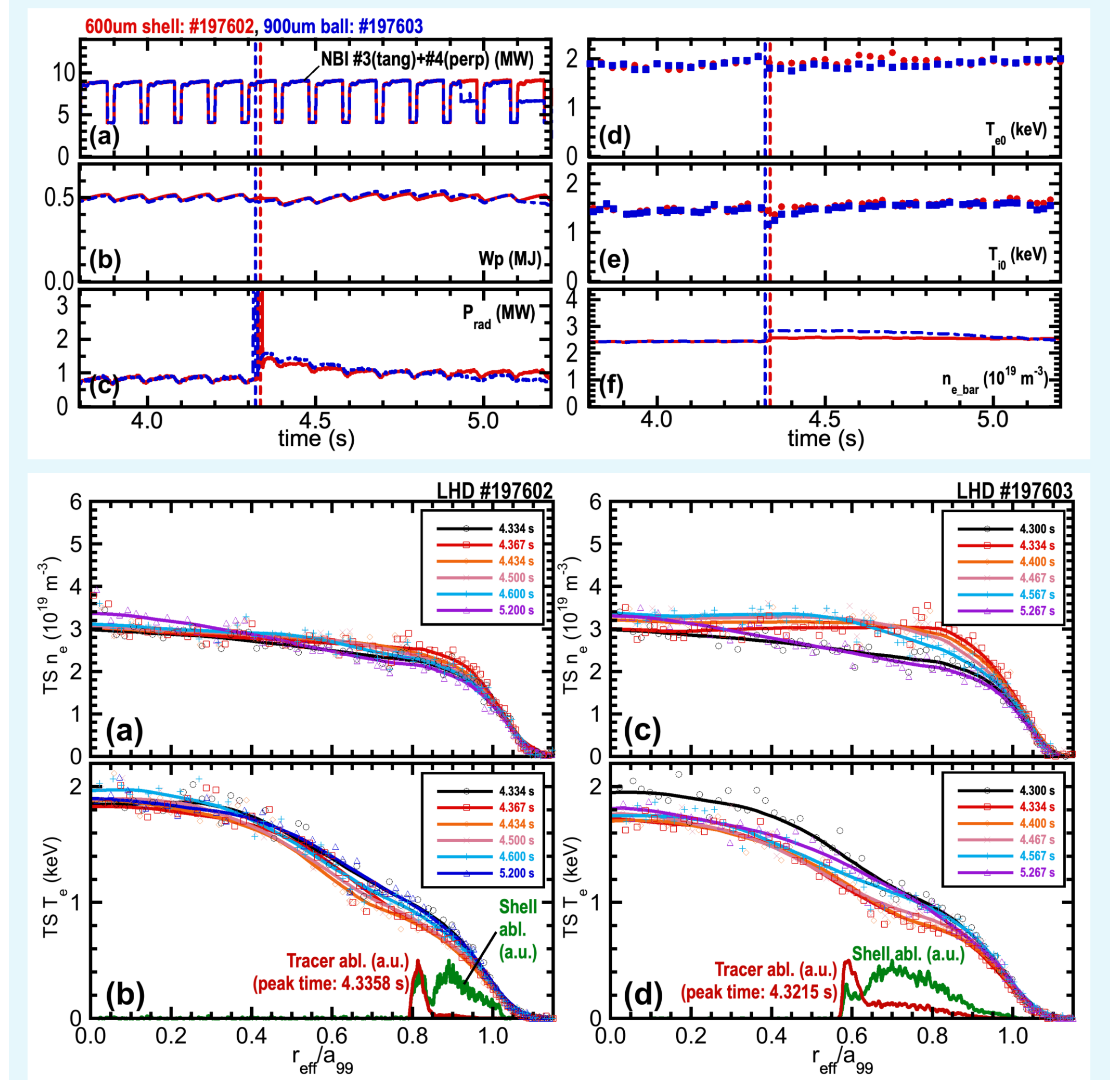
PEAKED DENSITY CASE



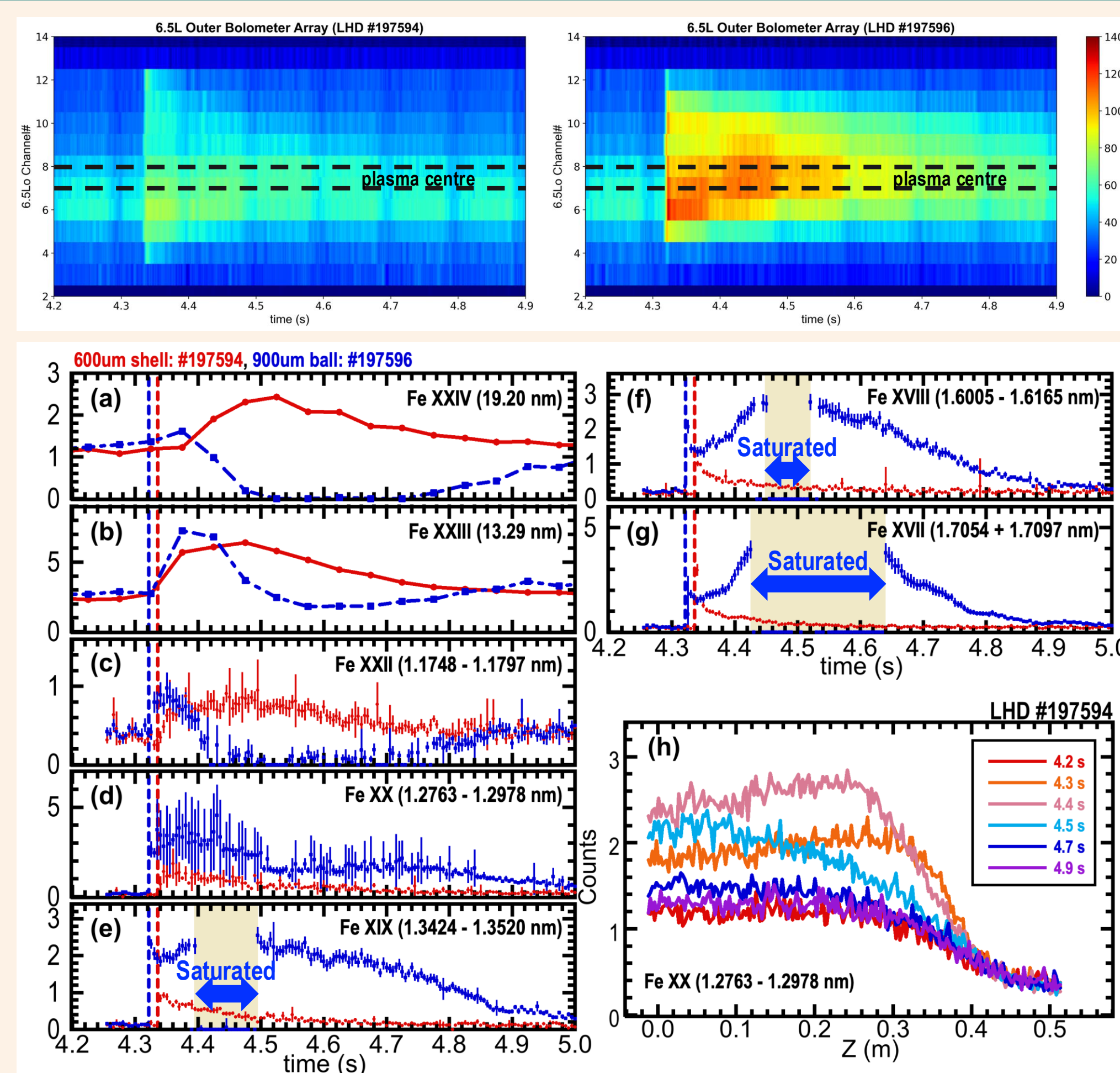
DISCUSSION

- #### TEMPORAL BEHAVIOURS
- To modify the electron density profile shape, different combinations of NBIs were employed
 - ✓ Peaked profile: Flat Perp. #5 + Mod. Perp. #4
 - ✓ Flat profile: Flat Tang. #3 + Mod. Perp. #4
 - Although the NBI combinations were different, the total injected heating power was nearly identical in both cases
 - However, plasmas including tangential NBI (flat n_e case) exhibited slightly higher T_e due to stronger electron heating
 - In contrast, plasmas heated only by perpendicular NBIs (peaked n_e case) showed slightly higher T_i because of enhanced ion heating
 - To investigate the effect of impurity deposition location, two TESPELs containing the same amount of impurity but having different sizes (600 μ m shell and 900 μ m ball) were injected
 - A significant reduction in the central T_e was observed only when the 900 μ m TESPEL was injected into the peaked-density plasma
- #### PROFILE RESPONSES
- ##### Peaked profile case
- For the 600 μ m TESPEL, the impact on the plasma profile was very limited
 - For the 900 μ m TESPEL, the T_e profile gradually flattened from the TESPEL penetration region toward the plasma core
- ##### Flat profile case
- For the 600 μ m TESPEL, the impact was similarly very limited
 - For the 900 μ m TESPEL, the T_e decreased in the region where the TESPEL deposited. However, this effect did not propagate into the plasma core

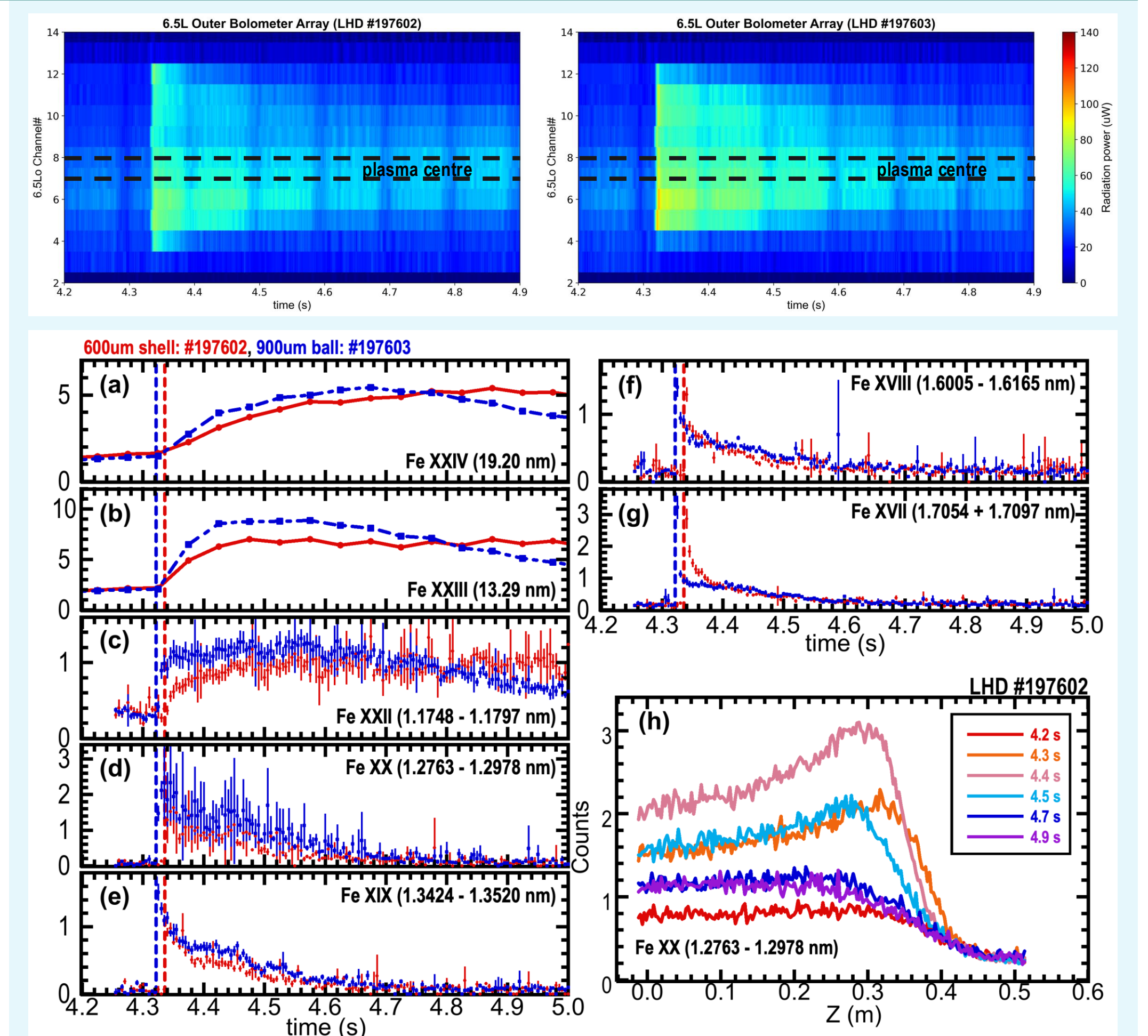
FLAT DENSITY CASE



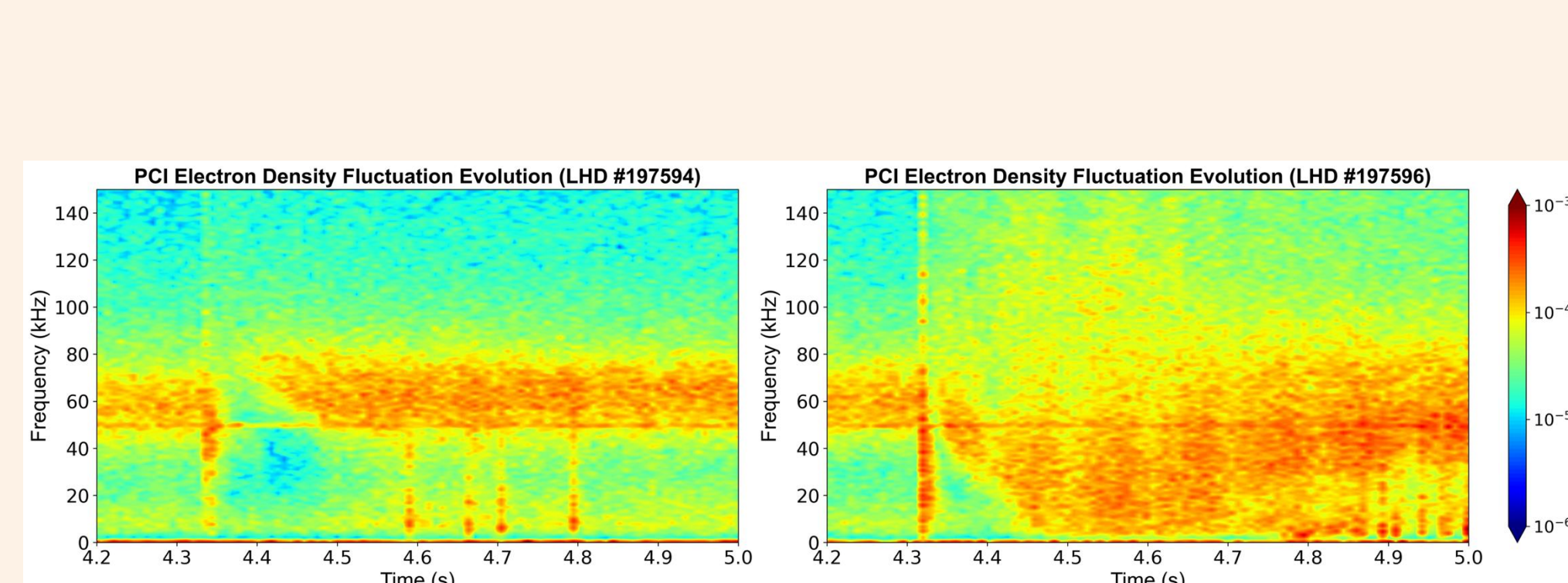
IMPURITY BEHAVIOURS



- #### PLASMA RADIATION
- Initial radiation response was stronger when impurities were deposited deeper in the plasma by the larger TESPEL
 - In the plasma with a peaked n_e profile plasma, the radiation region shifted toward the plasma center after the 900 μ m TESPEL, indicating impurity accumulation in the core region
- #### Fe LINE EMISSIONS IN EUV/VUV DOMAINS
- ##### Peaked profile case
- For the 600 μ m TESPEL, the Fe line emission gradually decayed to its pre-injection level. This is inconsistent with the expected impurity accumulation in a plasma with a peaked n_e profile
 - For the 900 μ m TESPEL, the dominant charge state of Fe ions shifted from higher charge-states to lower charge-states as the T_e profile became flatter
- ##### Flat profile case
- Differences in the temporal evolution were observed depending on the TESPEL size, i.e., the impurity deposition location
 - For the 600 μ m TESPEL (shallower deposition), the intensities of line emissions from higher charge-states increased more gradually than for the 900 μ m TESPEL (deeper deposition)
 - Assuming that the impurity transport coefficients do not vary strongly in space, impurities deposited farther from the plasma centre would require a longer time to accumulate in the core and subsequently diffuse outward
 - Time delay observed may provide information on the spatial structure of impurity transport coefficients



TURBULENCE RESPONSES



- For the injection of the larger TESPEL into the plasma with a peaked n_e profile, n_e fluctuations in the lower-freq. range increased simultaneously with the flattening of the T_e profile
- ##### Peaked profile case
- For the 600 μ m TESPEL, the reduction of the ~ 20 kHz n_e fluctuations lasted only about 0.1 s
- ##### Flat profile case
- The reduction of the ~ 20 kHz n_e fluctuations persisted for a much longer period, although it started earlier for the larger TESPEL
 - When considered together with the impurity behavior, these observations suggest that the presence of impurities may be responsible for the reduction of the fluctuations
 - Indicating an impact of impurities on turbulence?

